



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:

KONNO et al

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JUL 08 1998

Serial No.: 07/743,383

Group Art Unit: 1104

Filed: August 21, 1991

GROUP 2100

Examiner: G. Goudreau

For: METHOD FOR PRODUCING SEMICONDUCTOR INTEGRATED CIRCUITS AND  
APPARATUS USED IN SUCH METHOD

AMENDMENT UNDER 37 CFR §1.115

Honorable Commissioner  
of Patents and Trademarks  
Washington, D.C. 20231

January 7, 1993

Sir:

In response to the official Office Action dated October 5,  
1992, please amend the above-identified application as follows:

IN THE SPECIFICATION:

Page 4, line 22, delete "an";  
line 23, change "microwaves" to --microwave-- and  
delete "an".

Page 5, line 1, change "compound" to --compounds--;  
line 3, change "compound" to --compounds--;  
line 20, after "etching,", insert --can-- and change  
"remains" to --remain--;  
line 23, delete "an" and change "film" to --films--;  
line 26, change "contacting" to --being exposed  
to--.

Page 10, line 9, change "is" to --are--.

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